

L Number	Hits	Search Text	DB	Time stamp
2	0	removal same 'polymer residue' same 'fluorine' and @ad<=19990219 and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 10:54
3	0	'polymer residue' same 'fluorine' and @ad<=19990219 and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 10:54
4	10	'polymer residue' and 'fluorine' and @ad<=19990219 and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 10:55
11	162	'fluorine containing polymer' and @ad<=19990219 and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:24
13	1	'cleaning' with 'fluorine containing polymer' and @ad<=19990219 and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:25
14	2	("6272768").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:42
15	1		USPAT	2002/11/12 11:45
16	1		USPAT	2002/11/12 11:45
17	1		USPAT	2002/11/12 11:45
18	1		USPAT	2002/11/12 11:46
19	1		USPAT	2002/11/12 11:46
20	1		USPAT	2002/11/12 11:46
21	1		USPAT	2002/11/12 11:47
22	124	@ad<=19990219 and 'ultraviolet' same 'simultaneous' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:50
23	1	@ad<=19990219 and 'substrate cleaning' and 'ultraviolet' same 'simultaneous' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:53
25	4	@ad<=19990219 and 'semiconductor substrate' and 'ultraviolet' same 'simultaneous' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 12:07
27	5	@ad<=19990219 and 'semiconductor substrate' same 'cleaning' and 'ultraviolet' same 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 12:12
29	8	@ad<=19990219 and 'substrate cleaning' and 'ultraviolet' same 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 12:20
30	184	(438/715).ccls. ✓	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:44

31	184	(438/715).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:44
32	3732	(134/1-4).ccls. and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:51
33	774	((438/691) or (438/906)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:48
34	184	(438/715).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:47
35	1216	((438/693) or (438/974) or (204/510)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:49
36	94	((134/1-4).ccls. and @ad<=19990219) and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:51
37	18	((438/691) or (438/906)).CCLS.) and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:52
38	3	((438/715).CCLS.) and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:52
39	17	((438/693) or (438/974) or (204/510)).CCLS.) and 'ultraviolet' and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:52
-	12	(("6207583") or ("6303513") or ("5669979") or ("5814156") or ("4548688")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 08:45
-	10	((("6207583") or ("6303513") or ("5669979") or ("5814156") or ("4548688")).PN.) and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 09:08
-	100827	'photoresist' or 'photoreactive' near 'flourine containing'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 09:14
-	82441	('photoresist' or 'photoreactive' near 'flourine containing') and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 09:17
-	7631	(('photoresist' or 'photoreactive' near 'flourine containing') and @ad<=19990219) and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 11:25

-	149	((('photoresist' or 'photoreactive' near 'flourine containing') and @ad<=19990219) and 'ammonia' and 'plasma ashing')	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:24
-	283	'cleaning process' and @ad<=19990219 and 'fluorine containing'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 11:31
-	67	('cleaning process' and @ad<=19990219 and 'fluorine containing') and 'ultraviolet'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:20
-	234187	((438/\$) or (257/\$)).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 13:01
-	2	((438/\$) or (257/\$)).CCLS.) and 'volatilize residue'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 12:23
-	33	((438/\$) or (257/\$)).CCLS.) and 'dry cleaning' and 'ultraviolet'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 12:30
-	1130	((438/\$) or (257/\$)).CCLS.) and 'ammonia' and 'ultraviolet'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 12:34
-	10	((438/\$) or (257/\$)).CCLS.) and 'ammonia' and 'ultraviolet') and 'volatilize'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 12:34
-	30	('cleaning process' and @ad<=19990219 and 'fluorine containing') and 'ultraviolet') and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 12:51
-	51	((438/\$) or (257/\$)).CCLS.) and 'residue removal' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 13:02
-	876	((438/\$) or (257/\$)).CCLS.) and 'ammonia' and 'ultraviolet' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 13:04
-	7	((438/\$) or (257/\$)).CCLS.) and 'ammonia' and 'ultraviolet' and @ad<=19990219) and 'dry cleaning'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 13:24
-	280	(134/1.1).CCLS.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 13:25
-	3680	(134/1-4).ccls. and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:44

-	6	((134/1-4).ccls. and @ad<=19990219) and 'ultraviolet' and 'ammonia gas'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:07
-	11	((134/1-4).ccls. and @ad<=19990219) and 'fluorine residue'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:06
-	161	(438/715).ccls.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 13:43
-	3	((438/715).ccls.) and @ad<19990219 and 'volatilize'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:12
-	7	(("5129958") or ("5935340") or ("5207836")).PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:16
-	714	'fluorine' with 'photoresist'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:19
-	514	('fluorine' with 'photoresist') and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:18
-	0	'photoresist containing fluorine' and @ad<=1999019	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 14:19
-	188	'ashing photoresist' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 15:52
-	65	('ashing photoresist' and @ad<=19990219) and 'ultraviolet'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 15:52
-	0	((('ashing photoresist' and @ad<=19990219) and 'ultraviolet') and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 15:53
-	0	((('ashing photoresist' and @ad<=19990219) and 'ultraviolet') and 'NH3'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/05/10 15:53
-	0	'cleaning photoresist' with 'flourine containing' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:25
-	0	removal adj 'flourine containing residue' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:17

-	0	removal adj 'flourine containing' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:18
-	71	'removal' and 'flourine containing' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:18
-	0	('cleaning process' and @ad<=19990219 and 'fluorine containing') and 'ultraviolet' near 'simultaneous'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:21
-	8	@ad<=19990219 and 'fluorine containing residue'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:21
-	529	'organic photoresist' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:50
-	47	('organic photoresist' and @ad<=19990219) and 'ultraviolet' and 'simultaneous' and 'gas'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:54
-	512982	cleaning or removal same 'organic photoresist' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:42
-	28	cleaning same 'organic photoresist' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:54
-	11	'organic photoresist' with 'fluorine' and @ad<=19990219	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 10:38
-	1483	(cleaning or removal same 'organic photoresist' and @ad<=19990219) and 'ultraviolet' and 'simultaneous'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 09:57
-	437	((cleaning or removal same 'organic photoresist' and @ad<=19990219) and 'ultraviolet' and 'simultaneous') and 'ammonia'	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 11:48
-	2	("6272768").PN.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/11/12 10:15